

In re the Application of: NAKATA, Yoshihiro et al.

Group Art Unit: 2812

Serial No.: 10/807,174

Examiner: VO, Hai

Filed: March 24, 2004

P.T.O. Confirmation No.: 4205

FOR: SILICON-BASED COMPOSITION, LOW DIELECTRIC CONSTANT FILM, SEMICONDUCTOR DEVICE, AND METHOD FOR PRODUCING LOW

DIELECTRIC CONSTANT FILM

AMENDMENT UNDER 37 CFR §1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

January 30, 2006

Sir:

In response to the Office Action dated October 28, 2005, with January 28 and 29 being a Saturday and Sunday, please amend the above-identified application as follows: